

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	9	((156/345.43,345.48).CCLS.) and chamber and support and RF and C\$1F\$1 and S\$1F\$1	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/21 18:07
S2	676	(156/345.43,345.48).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/01/21 18:26
S3	0	((156/345.43,345.48).CCLS.) and (carbon adj flouride) and (sulfur adj fluoride)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/21 18:11
S4	3	US-4578559-\$.DID. OR US-5053104-\$.DID. OR US-6287981-\$.DID. OR US-629080B1-\$.DID. OR US-629179B1-\$.DID.	USPAT	OR	ON	2004/06/28 14:16
S5	4	((("6290806") or ("6291793"))).PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2004/06/28 14:17
S6	923	((s adj f) or SF or (sulfur adj fluor\$4)) and (fluorocarbon hydrofluorocarbon C4F6 C5F8 C4F8 CF2H2 CH2F2 "C.sub.4 F.sub.6" "C.sub.5 F.sub.8" "C.sub.4 F.sub.8" "CF.sub.2 H.sub.2" "CH.sub.2 F.sub.2")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/21 18:14
S7	160	((((s adj f) or SF or (sulfur adj fluor\$4)) and (fluorocarbon hydrofluorocarbon C4F6 C5F8 C4F8 CF2H2 CH2F2 "C.sub.4 F.sub.6" "C.sub.5 F.sub.8" "C.sub.4 F.sub.8" "CF.sub.2 H.sub.2" "CH.sub.2 F.sub.2")) and etch\$3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/21 18:12
S8	46	(((((s adj f) or SF or (sulfur adj fluor\$4)) and (fluorocarbon hydrofluorocarbon C4F6 C5F8 C4F8 CF2H2 CH2F2 "C.sub.4 F.sub.6" "C.sub.5 F.sub.8" "C.sub.4 F.sub.8" "CF.sub.2 H.sub.2" "CH.sub.2 F.sub.2")) and etch\$3) and (quartz or SiO)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/21 18:12

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S9	2	("4786352").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2004/06/28 17:12
S10	10	((156/345.43,345.48).CCLS.) and chamber and support and RF and C\$1F\$1 and S\$1F\$1	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/21 18:07
S11	0	((156/345.43,345.48).CCLS.) and (carbon adj flouride) and (sulfur adj flouride)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/21 18:11
S12	172	((s adj f) or SF or (sulfur adj fluor\$4)) and (fluorocarbon hydrofluorocarbon C4F6 C5F8 C4F8 CF2H2 CH2F2 "C.sub.4 F.sub.6" "C.sub.5 F.sub.8" "C.sub.4 F.sub.8" "CF.sub.2 H.sub.2" "CH.sub.2 F.sub.2")) and etch\$3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/21 18:12
S13	52	((s adj f) or SF or (sulfur adj fluor\$4)) and (fluorocarbon hydrofluorocarbon C4F6 C5F8 C4F8 CF2H2 CH2F2 "C.sub.4 F.sub.6" "C.sub.5 F.sub.8" "C.sub.4 F.sub.8" "CF.sub.2 H.sub.2" "CH.sub.2 F.sub.2")) and etch\$3) and (quartz or SiO)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/21 18:13
S14	1022	((s adj f) or SF or (sulfur adj fluor\$4)) and (fluorocarbon hydrofluorocarbon C4F6 C5F8 C4F8 CF2H2 CH2F2 "C.sub.4 F.sub.6" "C.sub.5 F.sub.8" "C.sub.4 F.sub.8" "CF.sub.2 H.sub.2" "CH.sub.2 F.sub.2"))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/21 18:16
S15	101	(S10 or S12 or S13 or S14) and @pd>="20040628"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:20
S16	742	(156/345.43,345.48).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/01/21 18:26

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S17	66	(S16) and @pd>="20040628"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:19
S18	1	(S10) and @pd>="20040628"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/21 18:31
S19	8	("20020132488" "4578559" "5053104" "5843847" "6287981" "6290806" "6291793" "6436812").PN. OR ("6737358"). URPN.	US-PGPUB; USPAT; USOCR	OR	ON	2005/01/21 18:36
S20	1	"5843847".PN.	USPAT; USOCR	OR	ON	2005/01/21 19:15
S21	1	"6436812".PN.	USPAT; USOCR	OR	ON	2005/01/21 19:16
S22	1	"20020132488".PN.	US-PGPUB	OR	ON	2005/01/21 19:18
S23	804	(156/345.43,345.48).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/01 15:19
S24	61	(S23) and @pd>="20050121"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/01 14:52
S25	12	((156/345.43,345.48).CCLS.) and chamber and support and RF and C\$1F\$1 and S\$1F\$1	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:20
S26	192	((s.adj f) or SF or (sulfur adj fluor\$4)) and (fluorocarbon hydrofluorocarbon C4F6 C5F8 C4F8 CF2H2 CH2F2 "C.sub.4 F.sub.6" "C: sub.5 F.sub.8" "C.sub.4 F.sub.8" "CF.sub.2 H.sub.2" "CH.sub.2 F.sub. 2")) and etch\$3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:20

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S27	62	(((((s adj f) or SF or (sulfur adj fluor\$4))) and (fluorocarbon hydrofluorocarbon C4F6 C5F8 C4F8 CF2H2 CH2F2 "C.sub.4 F.sub.6" "C.sub.5 F.sub.8" "C.sub.4 F.sub.8" "CF.sub.2 H.sub.2" "CH.sub.2 F.sub.2")) and etch\$3) and (quartz or SiO)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:20
S28	1147	((s adj f) or SF or (sulfur adj fluor\$4))) and (fluorocarbon hydrofluorocarbon C4F6 C5F8 C4F8 CF2H2 CH2F2 "C.sub.4 F.sub.6" "C.sub.5 F.sub.8" "C.sub.4 F.sub.8" "CF.sub.2 H.sub.2" "CH.sub.2 F.sub.2"))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:20
S29	127	(S25 or S26 or S27 or S28) and @pd>="20050121"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:20
S30	1361100	(H01L02\$).ipc.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/09/01 15:43
S31	951198	(H01L021\$).ipc.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/09/01 15:43
S32	868663	(H01L021\$).ipc.	EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/09/01 15:44
S33	230	S32 and (plasma) and (mix\$ or combin\$6) and etch\$ and (quartz or SiO2)	EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/09/06 15:00
S34	4	((("4874723") or ("4764245")).PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/06 15:53
S35	72911	((quartz or SiO\$1) with (wafer or substrate))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/09/06 16:02

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S36	16575	S35 same etch\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/09/06 15:55
S37	1147	((s adj f) or SF or (sulfur adj fluor\$4)) and (fluorocarbon hydrofluorocarbon C4F6 C5F8 C4F8 CF2H2 CH2F2 "C.sub.4 F.sub.6" "C.sub.5 F.sub.8" "C.sub.4 F.sub.8" "CF.sub.2 H.sub.2" "CH.sub.2 F.sub.2")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/06 15:55
S38	15	S37 and S36	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/09/06 16:03
S39	15772	((quartz or SiO\$1) near (wafer or substrate))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/09/06 16:02
S40	19	S37 and S39	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/09/06 16:03
S41	863	(156/345.43,345.48).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/05/01 14:52
S42	60	(S41) and @pd>="20050901"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/01 14:55
S43	18	(S41) and @pd>="20050901" and (@ad<="20020213" or @rlad<="20020213")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/01 15:49

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S44	12	((156/345.43,345.48).CCLS.) and chamber and support and RF and C\$1F\$1 and S\$1F\$1	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/01 15:25
S45	212	((s adj f) or SF or (sulfur adj fluor\$4)) and (fluorocarbon hydrofluorocarbon C4F6 C5F8 C4F8 CF2H2 CH2F2 "C.sub.4 F.sub.6" "C.sub.5 F.sub.8" "C.sub.4 F.sub.8" "CF.sub.2 H.sub.2" "CH.sub.2 F.sub.2")) and etch\$3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/01 15:25
S46	65	((s adj f) or SF or (sulfur adj fluor\$4)) and (fluorocarbon hydrofluorocarbon C4F6 C5F8 C4F8 CF2H2 CH2F2 "C.sub.4 F.sub.6" "C.sub.5 F.sub.8" "C.sub.4 F.sub.8" "CF.sub.2 H.sub.2" "CH.sub.2 F.sub.2")) and etch\$3) and (quartz or SiO)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/01 15:25
S47	1241	((s adj f) or SF or (sulfur adj fluor\$4)) and (fluorocarbon hydrofluorocarbon C4F6 C5F8 C4F8 CF2H2 CH2F2 "C.sub.4 F.sub.6" "C.sub.5 F.sub.8" "C.sub.4 F.sub.8" "CF.sub.2 H.sub.2" "CH.sub.2 F.sub.2"))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/01 15:25
S48	35	(S44 or S45 or S46 or S47) and @pd>="20050901" and (@ad<="20020213" or @rlad<="20020213")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/01 15:29
S49	838	(quartz plate) same etch\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2006/05/01 15:48
S50	69	((quartz or SiO or (silicon oxide)) plate) same (plasma etch\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2006/05/01 15:49
S51	58	(S50) and (@ad<="20020213" or @rlad<="20020213")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/01 15:49